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	5: Correction of Instrumental Mass Discrimination for Isotope Ratio Determination with Multi-Collector Inductively Coupled Plasma Mass Spectrometry
Sommario/riassunto	Edited by a very well-known and respected scientist in the field, this excellent practical guide is the first to cover the fundamentals and a wide range of applications, as well as showing readers how to efficiently use this increasingly important technique. A must-have guide for newcomers as well as established scientists seeking an overview of ICP-MS.